MEMS MICRORELAY: DESIGN, MODELING, AND SIMULATION

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SCHOOL OF MICROELECTRONICS ENGINEERING UNIVERSITI MALAYSIA PERLIS 2007

MEMS MICRORELAY: DESIGN, MODELING AND SIMULATION

by

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APPROVAL AND DECLARATION SHEET

This project report titled MEMS Microrelay: Design, Modeling and Simulation was prepared and submitted by Yap David (Matrix Number: 031030528) and has been found satisfactory in terms of scope, quality and presentation as partial fulfillment of the requirement for the Bachelor of Engineering (Electronics Engineering) in Universiti Malaysia Perlis (UniMAP).

Checked and Approved by

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School of Microelectronic Engineering Universiti Malaysia Perlis

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MEMS MIKROGEGANTI

ABSTRAK

Satu mikrogeganti baru telah dicipta dengan mengaplikasikan kesan kepiezoelektrikan dan kemudian dimodelkan menerusi perisian MEMS PRO L-EDIT CAD. Seterusnya, model tersebut telah dianalisis dan disimulasi dengan satu lagi perisian iaitu SamCef Field Oofelie FEM CAD dan MathCAD. Struktur jambatannya dan kesan daripada fenomena songsangan piezoelektrik daripada zink oksida membolehkan ia menghasilkan pergerakan menegak dan seterusnya menyambung litar keduanya sebagai fungsi geganti. Dengan voltan pandu 7V beza keupayaannya membolehkan ia menghasilkan pergerakkan sejauh 2μm dalam frekuansi resonannya kira-kira 335.87 kHz. Dengan daya sentuh sebanyak 4μN menghasilkan rintangan tutup litarnya yang rendah iaitu sekitar 0.3Ω. Galangan ciri bagi litar isyaratnya kira-kira 51Ω membolehkan ia mencapai galangan padanan yang baik untuk kegunaan dalam telekommunikasi dengan radio frekuensi, RF. Selain itu, saiz geganti yang halus, sifat-sifatnya yang unik tanpa kesan elektromagnet dan kebolehan berfungsi pada suhu 0°K membolehkan ia digunakan dalam pelbagai applikasi selain dalam kegunaan RF-nya.

MEMS MICRORELAY

ABSTRACT

A newly design of single pole single throw piezoelectric vertical actuation MEMS microrelay was successfully designed and modeled at the end of this project. This was implemented by using MEMS Pro LEdit CAD Modeler. Then, the finalize bimorph sandwich fixed-fixed model had been simulated and analyzed with numerical analyses by using SamCef Field Oofelie FEM CAD software and some other analyzer created with MathCAD. The design was based on Zinc Oxide phenomena of inverse piezoelectric effect and some other mechanical beam structure considerations. It is capable to be switched in low driving voltage about 7V for 2 μ m displacement distance at resonant frequency about 335.87 kHz. Its flat-to-flat contact surfaces have a good contact area and given a low on-resistance about 0.3 Ω with a contact force about 4 μ N. Then, its 51.537 Ω characteristic impedance of the microstrip line had given a perfect impedance matching. So that, this piezoelectric actuation microrelay is well suited in RF telecommunications due to its tiny size, do not produce magnetic fields nor affected by them, and its ability of piezoelectric effect continue to operate even at temperature close to 0°K enable it for a broad application area.

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LIST OF SYSBOLS, ABBREVIATIONS OR NOMENCLATURE

MEMS Micro Electro Mechanical Systems

CAD Computer Aided Design

FEA Finite Elements Analysis

DC Direct Currents

EM Electromagnetic

MIC Microwave integrated circuit

RF Radio Frequency

CPW Coplanar Waveguide

App. Appendix

Proc. Process

iges Initial Graphics Exchange Specification, a neutral data format that allows

the digital exchange of information among Computer-aided designs

(CAD) systems.

s Total strain (Strain vector)

S Compliance matrix of transducer

T Mechanical stress

d Piezoelectric material constant

E Electrical field

 ε Permittivity of material

Radius of curvature S_{long} Longitudinal strain t_p/t_e Piezoelectric layer/ Elastic layer thickness $A/A_e/A_p$ Cross sectional area of the elastic layer/piezoelectric layer $E_e/E_p/E_B$ Young's Modulus of the elastic layer/ piezoelectric layer/ beam $I_e/I_p/I_B$ Elastic layer/ Piezoelectric layer/ Beam cross sectional inertial moment Entire layer width w Vertical displacement at any location (x) of the cantilever $\delta(x)$ VVoltage $\phi(x)$ Angular displacement at any location (x) of the cantilever Partial a or b length of beam l_a, l_b L,W,TTotal Length, width and thickness of the beam K Force constant CCoefficient constant of beam Force \boldsymbol{F} M Mass Normalized natural frequency ω_n Quality factor QNatural frequency or resonant frequency f_n Entire material mass density ρ

δ

Skin depth

- μ_o Relativity permittivity
- *R* Conductance resistance
- m Ramp of the graph